

IN THE PATENT AND TRADEMARK OFFICE

In re patent application of:)	Group Art Unit: 2813
)	
)	Examiner: Schillinger, Laura
For: Process For High-Dielectric Constant)	
Metal-Insulator Metal Capacitor In VLSI)	
Multi-Level Metallization Systems)	
)	
Prior Application Number:)	
09/891324)	Attorney Docket:
)	10004808-1
Continuation Prosecution Date:)	
October 22, 2003)	
)	
Prior Application Filing Date:)	Palo Alto, CA
June 27, 2001)	October 22, 2003
)	

PRELIMINARY AMENDMENT

Commissioner of Patent and Trademarks
Assistant Commissioner for Patents
Washington, DC 20231


Sir:

Please enter this amendment prior to examination of this continuing application.

AMENDMENT

Please cancel claims 14-19 without prejudice.

Respectfully Submitted,


Richard P. Lange
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